IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: LEE, Yueh-Chuan et al

Conf.:

Appl. No.:

NEW

Group:

Filed:

October 30, 2003

Examiner:

For:

SEMICONDUCTOR STRUCTURE WITH PARTIALLY ETCHED GATE AND METHOD OF FABRICATING THE

SAME

PRELIMINARY AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 October 30, 2003

Sir:

following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application.

This amendment includes:

Amendments to the Specification

Remarks